An Effective Longitudinal Space-Charge Impedance Model for Beams with Non-uniform and Non-axisymmetric Transverse Density

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Use of a one-dimensional model of longitudinal space-charge (SC) impedance has been proposed [1, 2] for studying the microbunching instability in single-pass delivery systems relevant for the next generation of FELs. For beams with uniform transverse density and circular cross-section of radius \( r_b \) the SC impedance can be expressed in a handy analytical form, making this model particularly convenient. In this report we show how with an appropriate choice of \( r_b \) one can use this as an effective-beam model to approximate beams with non-axisymmetric and non-uniform transverse densities.

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I. INTRODUCTION

Consider a single electron at \((x', y', z')\) moving along the \( z \) axis at relativistic velocity with relativistic factor \( \gamma \). The longitudinal electric field as seen in the lab frame is [3]

\[
E_z(x, y, z) = \frac{e}{4\pi\varepsilon_0} \frac{(z - z')\gamma}{[(x - x')^2 + (y - y')^2 + (z - z')^2\gamma^2]^{3/2}}.
\]  

Similarly, a distribution of electrons with density \( \rho_\perp(x, y) \lambda e^{ikz} \) where \( \lambda \) is the longitudinal particle density and \( \rho_\perp(x, y) \) the transverse density (normalized to unity \( \int \rho_\perp(x', y')dx'dy' = 1 \)), will generate a longitudinal electric field

\[
E_z(x, y, z) = \frac{e\lambda\gamma}{4\pi\varepsilon_0} \int \frac{(z - z')\rho_\perp(x', y')e^{ikz'}dx'dy'dz'}{[(x - x')^2 + (y - y')^2 + (z - z')^2\gamma^2]^{3/2}}
= \frac{e\lambda\gamma}{4\pi\varepsilon_0} e^{ikz} \int \frac{\zeta \rho_\perp(x', y')e^{-ik\zeta}dx'dy'd\zeta}{[(x - x')^2 + (y - y')^2 + \zeta^2\gamma^2]^{3/2}}.
\]  

If we set

\[
I_k = -\gamma \int \frac{\zeta \rho_\perp(x', y')e^{-ik\zeta}dx'dy'd\zeta}{[(x - x')^2 + (y - y')^2 + \zeta^2\gamma^2]^{3/2}},
\]  

we have

\[
E_z = -\frac{e\lambda}{4\pi\varepsilon_0} e^{ikz} I_k.
\]  

The longitudinal space-charge (SC) impedance (per unit length) for wave-number \( k \) is defined as

\[
\hat{Z}(k) = \frac{1}{4\pi\varepsilon_0} I_k = \frac{Z_0}{4\pi} I_k,
\]  

where \( Z_0 = 120\pi \) \( \Omega \) is the vacuum impedance.

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II. TRANSVERSELY UNIFORM BEAM WITH CIRCULAR CROSS SECTION

The transverse density is defined as \( \rho_\perp(x, y) = 1/r_b^2 \) for \( x^2 + y^2 \leq r_b^2 \) and \( \rho_\perp(x, y) = 0 \) for \( x^2 + y^2 > r_b^2 \). With a change to cylindrical coordinates the integral \( I_k \) reads

\[
I_k = -\frac{2\gamma}{r_b^2} \int_0^{r_b} dr \int_{-\infty}^{\infty} d\xi \frac{\xi e^{-ik\xi}}{(1 + \xi^2)^{3/2}}
= -\frac{2}{\gamma r_b^2} \int_{-\infty}^{\infty} dt \int_0^{r_b} dr e^{-iktr/\gamma} = -\frac{2i}{kr_b} \int_{-\infty}^{\infty} e^{-itx/\gamma} \frac{e^{-ix^2/\gamma}}{(1 + t^2)^{3/2}} dt,
\]

where we have defined \( \xi = kr_b/\gamma \) and have set the observation point on the axis \( x = y = 0 \). From the table of integrals, \( \int_{-\infty}^{\infty} dt/(1 + t^2)^{3/2} = 2 \) and

\[
\int_{-\infty}^{\infty} \frac{e^{-itx/\gamma}}{1 + t^2} dt = 2\xi K_1(\xi),
\]

where \( K_1 \) is Bessel function \( K_1 \). We have

\[
I_k = i \frac{4}{kr_b} \left[ 1 - \xi K_1(\xi) \right] = \frac{4i}{\gamma r_b} \frac{1 - \xi K_1(\xi)}{\xi},
\]

in agreement with the expression reported in [4].

For \( \xi \to \infty \), \( K_1(\xi) \) decreases exponentially while for small \( \xi \) we have \( K_1(\xi) \simeq 1/\xi + \xi[\log(\xi/2) + \gamma_E - 1/2]/2 \), where \( \gamma_E \) is the Euler constant \( \simeq 0.577 \) Therefore we have the following limiting forms:

\[
I_k(\xi \to \infty) = i \frac{4}{kr_b},
\]

\[
I_k(\xi \to 0) = -i \frac{k}{\gamma^2} \left[ 2\log(\xi) + 2\gamma_E - 2 \log(2) - 1 \right] \simeq -i \frac{2k}{\gamma^2} \log \left( \frac{kr_b}{1.85\gamma} \right),
\]

where \( 2\gamma_E - 2 \log(2) - 1 \approx -1.23 \)

If the observation point is off-axis at a distance \( r \) from the center the expression (8) for \( I_k \) should be replaced [4] by

\[
I_k(r) = i \frac{4}{\gamma r_b} \frac{1}{\xi} \left[ 1 - \xi K_1(\xi) I_1 (kr/\gamma) \right],
\]

where \( I_1 \) is also a Bessel function.

It is interesting to compare \( I_k \) on-axis (8) with the average of (11) over the transverse density:

\[
\langle I_k \rangle_r = \frac{\int_0^{r_b} I_k(r) \rho_\perp(r) dr}{\int_0^{r_b} \rho_\perp(r) dr} = \frac{4i}{\gamma r_b} \frac{1 - 2K_1(\xi) I_1(\xi)}{\xi}.
\]
Because $I_1(\xi) \simeq \xi/2$ for small $\xi$ and $I_1(\xi)$ decreases exponentially for large $\xi$, the limiting behavior of (12) at high and small frequencies is the same as (9) and (10). At intermediate frequencies, however, the averaged longitudinal field is noticeable smaller (red curve in Fig. 1). In the presence of a perfectly conducting pipe of radius $r_p$ concentric with the charge distribution the expression (8) for $I_k$ should be replaced by

$$I_k = i \frac{4}{\gamma r_b} \frac{1}{\xi} \left[ 1 - \xi \left( K_1(\xi) + K_0(\xi r_p/r_b) \frac{I_1(\xi)}{I_0(\xi r_p/r_b)} \right) \right].$$

(13)

The high frequency limit $\xi \to \infty$ is the same as (9) as both $K_0(\xi r_p/r_b)$ and the ratio $I_1(\xi)/I_0(\xi r_p/r_b)$ decrease exponentially with $\xi$, whereas

$$I_k(\xi \to 0) = i \frac{4}{\gamma r_b} \frac{\xi}{4} \left[ 2 \log \left( \frac{r_p}{r_b} \right) + 1 \right],$$

(14)

having used $K_0(\xi) = -[\gamma_E + \log(\xi/2)] + O(\xi^2)$, $I_1(\xi) \simeq \xi/2$, and $I_0(\xi) \simeq 1$ for $\xi \to 0$. The effect of the boundary becomes significant at low frequencies below $\xi \simeq r_b/r_p$ or wavelengths $\lambda > 2\pi r_p \gamma$. See Fig. 2.

### III. AXIS-SYMMETRIC BEAM WITH TRANSVERSE GAUSSIAN DENSITY.

The transverse density is defined as $\rho_\perp(x, y) = e^{-(x^2+y^2)/2\sigma^2}/2\pi\sigma^2$. After changing to cylindrical coordinates we have

$$I_k = i \frac{\xi}{\gamma \sigma} \sqrt{\frac{2}{\pi}} \int_{-\infty}^{\infty} \frac{e^{-t^2/2} \text{erfi}(t/\sqrt{2}) dt}{(\xi^2 + t^2)^{3/2}},$$

(15)

where the erfi($t$) function is defined as $\text{erfi}(t) = (2/\sqrt{\pi}) \int_0^t e^{x^2} dx$, and $\xi = k \sigma / \gamma$.

To study the limiting form of the above expression at high and low frequencies consider the function

$$F(s) = \sqrt{\frac{\pi}{2}} \int_{-\infty}^{\infty} \frac{te^{-t^2/2} \text{erfi}(t/\sqrt{2}) dt}{(s + t^2)^{3/2}}.$$  

(16)

The function in the numerator of the integrand of (16) is zero at $t = 0$, and for large $t$ tends asymptotically to $\sqrt{2/\pi}$. In the limit of large $s$ most of the contribution from the integrand comes for large $t$. We can then approximate

$$F(s) \simeq \sqrt{\frac{\pi}{2}} \int_{-\infty}^{\infty} \frac{\sqrt{2/\pi} dt}{(s + t^2)^{3/2}} = \frac{2}{s}.$$  

(17)
analytically. To this end we replace the numerator in the integrand of (16) with the first non-vanishing term of its
expression obtained for round beams:

\[
\int_{0}^{\Lambda} \frac{t^2 dt}{(s + t^2)^{3/2}} = 2 \left[ -\frac{t}{\sqrt{t^2 + s}} + \log(t + \sqrt{t^2 + s}) \right]_{t=0}^{t=\Lambda} = 2 \left[ -\frac{\Lambda}{\sqrt{\Lambda^2 + s}} + \log \left( \frac{\Lambda + \sqrt{\Lambda^2 + s}}{\sqrt{s}} \right) \right].
\]  

(18)

where \( \Lambda \) is some cut-off. In the limit \( s \to 0 \) we read off the coefficient of \( \log(s) \) to find \( A = -1 \). The coefficient \( B \) can
then be computed numerically as the difference \( B = F(s) - A \log(s) \) for \( s \) sufficiently small. We found \( B \approx 0.116 \).

We can now write the limiting forms of the integral in the high and low frequency limits

\[
I_k(\xi \to \infty) = i \frac{2}{\gamma \sigma \xi} \frac{2i}{\sigma^2 k},
\]

(19)

\[
I_k(\xi \to 0) = -i \frac{\xi}{\gamma \sigma} [2 \log(\xi) - 0.116] = -i \frac{2k}{\gamma^2} \log \left( \frac{k\sigma}{1.06\gamma} \right),
\]

(20)

By comparing (19) and (20) to (9) and (10) respectively we can define a uniform beam with transverse size \( r_b \)
‘equivalent’ to a gaussian beam with rms size \( \sigma \). In the high frequency limit \( r_b^{eq} = \sqrt{2}\sigma \), whereas in the low frequency
limit \( r_b^{eq} \approx (1.85/1.06)\sigma = 1.74\sigma \). A numerical evaluation of (15) shows that at intermediate frequencies \( r_b^{eq} \) falls in
the interval \([\sqrt{2}, 1.74]\). See Fig. 3.

IV. TRANSVERSALLY UNIFORM BEAM WITH ELLIPTICAL CROSS SECTION

The transverse density is defined as \( \rho_\bot(x', y') = 1/\pi ab \) for \((x/a)^2 + (y/b)^2 \leq 1 \) and \( \rho_\bot(x', y') = 0 \) outside the ellipse.
For observation point on axis the integral can be reduced to

\[
I_k = \frac{i}{\pi k} \left[ \frac{4\pi}{ab} - \frac{2k}{\gamma} \int_{0}^{2\pi} \frac{K_1(k\alpha(\phi)/\gamma)}{\alpha(\phi)} d\phi \right],
\]

(21)

where \( \alpha(\phi) = \sqrt{a^2 \cos^2 \phi + b^2 \sin^2 \phi} \).

In the high frequency limit the contribution from the integral vanishes as the Bessel function \( K_1 \) decreases exponentially
and the limiting expression for \( I_k \) is easily found. At low frequency the calculation is slightly more involved
but can be still be expressed in terms of elementary functions by making use of the limiting expression for \( K_1 \) for
small argument and the integral \( \int_{0}^{2\pi} \log(1 + c^2 \sin^2 t) = 4\pi \log([1 + \sqrt{1 + c^2}]/2) \). The result is very similar to the
expression obtained for round beams:

\[
I_k(\xi \to \infty) = \frac{4}{kab}
\]

(22)

\[
I_k(\xi \to 0) = -\frac{k}{\gamma^2} \left[ 2 \log \left( \frac{k(a + b)}{2\gamma} \right) + 2\gamma e - 2 \log(2) - 1 \right] \approx -\frac{2k}{\gamma^2} \log \left( \frac{k}{1.89\gamma} \frac{a + b}{2} \right),
\]

(23)
V. TRANSVERSALLY GAUSSIAN BEAM WITH UNEQUAL RMS SIZES

The transverse density in this case is defined as \( \rho_\perp(x, y) = e^{-(x^2/2\sigma_x^2 + y^2/2\sigma_y^2)} / (2\pi\sigma_x\sigma_y) \) and the expression \( I_k \) can be reduced to

\[
I_k = i \frac{k}{2\pi\gamma^2} \int_0^{2\pi} d\phi F \left( \frac{k^2 \alpha^2(\phi)}{\gamma^2} \right),
\]

where \( \alpha(\phi) = \sqrt{\sigma_x^2 \cos^2 \phi + \sigma_y^2 \sin^2 \phi} \) and \( F(s) \) was defined in (16). For large \( s, F(s) \approx 2/s \) and therefore

\[
I_k(k \to \infty) = i \frac{k}{\pi\gamma^2} \int_0^{2\pi} d\phi \frac{\alpha^2(\phi)}{\alpha^2(\phi)} \approx i \frac{2}{k\sigma_x\sigma_y}.
\]

For small \( s \) we use the approximation \( F(s) \approx -\log(s) + 0.116 \) as in Sec. III and obtain:

\[
I_k(\xi \to 0) = i \frac{k}{\gamma} \left[ 2 \log \left( \frac{\sigma_x + \sigma_y}{\gamma} \right) - 0.116 \right] = i \frac{2k}{\gamma^2} \log \left( \frac{\sigma_x + \sigma_y}{2} \frac{k}{1.06}\right).
\]

VI. CONCLUSIONS

A simple and convenient model to study longitudinal effects of space charge is that of a round beam with transverse uniform density. Most often, the beam is neither axis-symmetric or uniform, but we would still like use an ‘equivalent’ round and uniform beam model because of its simplicity. For gaussian beams with rms sizes \( \sigma_x \) and \( \sigma_y \), limiting expressions at small frequencies suggest that we could use an equivalent axis-symmetric uniform beam with radius \( r_b \approx 1.74(\sigma_x + \sigma_y)/2 \). This is in substantial agreement with the expression suggested in [1]. Numerical calculations show that this choice is reasonably accurate over a large spectrum of frequencies and moderate aspect-ratios. Significant deviations only begin to occur at high frequencies for \( k(\sigma_x + \sigma_y)/2\gamma > 1 \). We should remark that the definition of equivalent beam is limited to consideration of the on-axis longitudinal electric field. One may argue that a more meaningful quantity is the longitudinal electric field averaged over the transverse beam density. For round beams we showed that this can be up to about 20% smaller than the on-axis field for a range of frequencies in the neighborhood of \( kr_b/\gamma \approx 1 \).
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[1] Z. Huang, M. Borland, P. Emma, J. Wu, C. Limborg, G. Stupakov, and J. Welch, Phys. Rev. ST Accel. Beams 7, 074401 (2004); the authors recommend using $r_b = 1.7(\sigma_x + \sigma_y)/2$.


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